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Subpicosecond time-resolved Raman studies of field-induced transient transport in an InxGa1−xAs-based p-i-n semiconductor nanostructure

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[Subpicosecond time-resolved Raman studies of field-induced transient](http://dx.doi.org/10.1063/1.2420782) transport in an In*x***Ga1−***x***As-based** *p***-***i***-***n* **[semiconductor nanostructure](http://dx.doi.org/10.1063/1.2420782)**

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Electron transient transport in an In_xGa_{1−*x*}As-based ($x=0.53$) *p*-*i*-*n* nanostructure under the application of an electric field has been studied by time-resolved Raman spectroscopy on a subpicosecond time scale and at $T=300$ K. The experimental results reveal the time evolution of the electron distribution function and electron drift velocity with subpicosecond time resolution. These experimental results are compared with those of both InP-based and GaAs-based *p*-*i*-*n* nanostructures and provide a consistent understanding and better insight of electron transient transport phenomena in semiconductors. © *2006 American Institute of Physics*. [DOI: [10.1063/1.2420782](http://dx.doi.org/10.1063/1.2420782)]

Recently, electronic devices with sizes of the order of 0.1 μ m or smaller have become achievable. This capability, when coupled with a typical device operation voltage (which is of the order of 1 V), suggests that carrier transient effects may be the dominant transport properties for electrons or holes in semiconductor nanostructures.

Many theoretical (mainly, Monte Carlo simulations) and experimental efforts $1-15$ have been made to investigate these interesting yet challenging transient carrier transport phenomena in semiconductors. Recently, Grann *et al.*^{[16](#page-3-2)[–20](#page-3-3)} have investigated nonequilibrium electron distributions, electron drift velocities, and nonequilibrium longitudinal optical phonon populations in a GaAs-based *p*-*i*-*n* nanostructure by using picosecond/subpicosecond transient/time-resolved Raman spectroscopy. These authors have directly confirmed the existence of electron velocity overshoot phenomenon in semiconductors. In spite of tremendous efforts on the study of carrier transient transport phenomena, lack of a better insight for these transient electron transport phenomena still prevails. In this letter, subpicosecond time-resolved Raman spectroscopy has been used for probing electron transient phenomena in an $In_{0.53}Ga_{0.47}As$ -based *p*-*i*-*n* nanostructure. Our experimental results reveal the time evolution of the electron distribution as well as the electron drift velocity with subpicosecond time resolution.The detailed structure of the $In_{0.53}Ga_{0.47}As-based nanostructure used in this work has$ been shown elsewhere.²¹ The Zn-doped *p*-type layer and Sidoped *n*-type layer together serve as a capacitor and provide a uniform electric field across the active region of the sample. We estimate the capacitance in our sample configuration to be $C \approx 2.6 \times 10^{-11}$ F. Since the resistance of the sample is $R \approx 100 \text{ k}\Omega$, with such a long *RC* time constant the capacitance of the sample structure will not affect our subpicosecond measurements in any way.

The sample is excited and probed by the outputs of two optical parametric amplifiers (OPA1 and OPA2) (Ref. [22](#page-3-5)) pumped by a common pulse from a Ti-sapphire amplifier system which is composed of the ultrastable Millennia/ Tsunami short pulse oscillator and the Spitfire regenerative amplifier with the Merlin Nd:YLF pump laser. The output from OPA1 has a pulse width of about 100 fs (full width at half maximum) and is chosen to operate at photon energy of $\hbar\omega_{\text{pump}}\cong1.05$ eV. We estimate the absorption depth of the sample at such excitation laser photon energy to be about 6500 Å. This is used to excite electron-hole pairs in the $In_{0.53}Ga_{0.47}As-based p-i-n semiconductor nanostructure. The$ output from OPA2 has the same pulse width and is used to probe the electron distributions with photon energy of $\hbar\omega_{\text{probe}} \approx 0.85$ eV. This experimental arrangement ensures that negligible electrons escape from the probe region during the time-resolved Raman measurements. The photoexcited electron-hole pair density was estimated from the average laser power, focused spot size on the sample surface, and the absorption depth at the excitation laser wavelength. The backscattered Raman signals were collected and analyzed by a standard computer-controlled Raman system, which includes a double spectrometer, a photomultiplier tube, and associated photon counting electronics. All the data were taken at *T*=300 K. The single-particle scattering experiments, which were used to measure directly the electron distributions, were conducted in the $Z(X, Y)\overline{Z}$ scattering geometry, where $X = (100)$, $Y = (010)$, and $Z = (001)$. This scattering configuration ensures the detection of a scattered light signal from only spin-density fluctuations.^{23,[24](#page-3-7)} The effective electric field intensity was determined by using the Franz-Keldysh effect, as demonstrated in Ref. 25 . The nonequilibrium elec-

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FIG. 1. Nonequilibrium electron distribution for an $In_{0.53}Ga_{0.47}As$ -based *p-i-n* nanostructure measured at an electric field intensity *E*=20 kV/cm, a photoexcited electron-hole pair density $n \approx 5 \times 10^{16}$ cm⁻³, and for time delays of (a) 120 fs, (b) 400 fs, and (c) 3 ps. The time evolution of electron distributions provides a better insight of electron transient transport phenomena in semiconductors.

tron distributions are directly measured in a way similar to Ref. [20.](#page-3-3)

A typical nonequilibrium electron distribution for an $In_{0.53}Ga_{0.47}As$ -based nanostructure, taken at an electric field intensity *E*=20 kV/cm, with electron-hole pair density *n* \approx 5 × 10¹⁶ cm⁻³ and at a time delay Δt = 400 fs between the pump and probe pulses, is shown in Fig. $1(b)$ $1(b)$. We have found that the electron distribution shifts toward the −**E** direction, as expected. The electron distribution function cannot be fitted with either a shifted Fermi-Dirac or a Maxwell-Boltzmann distribution, suggesting that electron distribution during the transient is in an extremely nonequilibrium state. A sharp cutoff in the electron velocity near 1.5×10^8 cm/s is observed, indicative of both the onset of electron intervalley scattering processes and the velocity saturation due to the nonparabolic effective mass. We note that impact ionization has a minimal effect on the cutoff velocity because it happens at a time scale of 100 ps–1 ns. The electron drift velocity in Fig. $1(b)$ $1(b)$ has been found to be $V_d = 6.9 \pm 0.7$ $\times 10^7$ cm/s.

Figure [2](#page-2-1) shows the electron drift velocity as a function of the time delay for an $In_{0.53}Ga_{0.47}As$ -based $p-i-n$ nanostructure, taken at an electric field intensity *E*=20 kV/cm. This is contrasted with equivalent curves taken in the other two material systems—GaAs and InP. We observe that the electron drift velocity increases linearly with the time delay during the first 200 fs, which provides an unambiguous evidence of electron ballistic transport under our experimental conditions. After 200 fs, the drift velocity increases sublinearly indicating the onset of various electron scattering processes. It peaks at around 6.9×10^7 cm/s at $\Delta t = 400$ fs, and then

decreases gradually toward its steady-state value of about which electrons travel

 3.0×10^7 cm/s. This latter value is also inferred from ensemble Monte Carlo studies of bulk In_xGa_{1−*x*}As at this composition.

We have also performed similar experiments on a GaAsbased *p*-*i*-*n* and an InP-based *p*-*i*-*n* nanostructure, in which we kept the electron excess energy the same, i.e., ΔE ≈ 0.30 eV. These results are also shown in Fig. [2.](#page-2-1) There are three interesting features that are worthwhile pointing out. (1) The peak value of electron drift velocity is significantly larger for $In_{0.53}Ga_{0.47}As than for either GaAs or InP, and it$ occurs at a later time (400 fs for $In_{0.53}Ga_{0.47}As compared$

FIG. 2. Electron drift velocity as a function of time delay for an In_{0.53}Ga_{0.47}As-based *p*-*i*-*n* nanostructure (open circles), an InP-based *p*-*i*-*n* nanostructure (solid circles), and a GaAs-based *p*-*i*-*n* nanostructure (open squares). The straight line drawn between $\Delta t=0$ and 200 fs on the data of an This article is copyrighted as indicated in the article. Reuse of AIP content is subjected for the analysis of pri-n panostructure indicates the time interval during to IP:
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with 300 fs for InP and 250 fs for GaAs). This is partly because of the smaller electron effective mass and partly because of larger energy separation between Γ and *X* valleys for $In_{0.53}Ga_{0.47}As.$ (2) The slope from the ballistic portion of the data is steeper for $In_{0.53}Ga_{0.47}As than for GaAs or InP,$ which reflects the fact that, even for an energy of about 0.30 eV above the conduction band, $In_{0.53}Ga_{0.47}As$ has a smaller effective mass than either GaAs or InP. (3) The observed maximum electron drift velocity is substantially higher in InP than in GaAs. This is primarily due to the fact that the energy separation between the Γ and *X* valleys is significantly larger in InP than in GaAs. All of these results are consistent with our previous understanding of electron transient transport in these semiconductors.

To gain a better insight of the electron transient phenomena, we have plotted in Fig. [1](#page-2-0) the electron distribution for the In_{0.53}Ga_{0.47}As nanostructure, taken at $E=20$ kV/cm and at a variety of time delays: $\Delta t = 120$ fs, 400 fs, and 3 ps, as indicated. For $\Delta t = 120$ fs, the electron distribution resembles a symmetric, shifted distribution, suggesting that electrons have been accelerated and moved rigidly for the same amount in velocity space, which is consistent with our observation in Fig. [2](#page-2-1) that electrons travel ballistically during the first 200 fs. As a matter of fact, for time delay between 0 and 200 fs, the electron drift velocity is linearly proportional to the elapsed time and to the magnitude of applied electric field. This is usually referred to as "electron ballistic transport." As the time delay progressively increases to Δt =400 fs, the electron distribution exhibits an extremely nonequilibrium, nonsymmetric nature. At this time delay, some elastic as well as inelastic electron scattering processes become effective. The electron drift velocity can keep increasing with the time delay but it can no longer increase linearly because these electron scattering processes efficiently randomize electron momentum and reduce the electron drift velocity. Nevertheless, if the electric field intensity is sufficiently large, the acquired electron drift velocity during this time interval can be substantially larger than its steady-state value. This is manifested in the time delay between 200 and 400 fs in Fig. [2.](#page-2-1) This is commonly called "electron velocity overshoot." When the time delay increases even further to $\Delta t = 3$ ps, the electron distribution has been found to be approximately symmetric but significantly broader than that at Δt =120 fs. This is because at this long time delay all of the elastic and inelastic electron scattering processes become operative. The electron distribution spreads out and the electron drift velocity gradually approaches its steady-state value.

We note that the temperature will have only a small effect on our results, while the electric field strength is the important quantity, transient transport does not occur in a small field, and the overshoot is much more pronounced in a large field.

In conclusion, we have used subpicosecond timeresolved Raman spectroscopy to interrogate electron transient transport in an $In_{0.53}Ga_{0.47}As-based p-i-n semiconduc-$ tor nanostructure under the application of an electric field. Our experimental results reveal the time evolution of the electron distribution function and the electron drift velocity with subpicosecond time resolution. These experimental results are compared with those of InP-based *p*-*i*-*n* and GaAsbased *p*-*i*-*n* nanostructures and provide a consistent understanding and better insight of electron transient transport phenomena in semiconductors.

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